

Notice of References Cited		Application N 10/085,935	Applicant(s) Takeda et al.	
		Examiner Sin J. Lee	Group Art Unit 1752	Pag <u>1</u> of <u>1</u>

U.S. PATENT DOCUMENTS

*	DOCUMENT NO.	DATE	NAME	CLASS	SUBCLASS
A	6,589,705 B1	7-8-03	Sato et al.	430	290.1
B	5,164,286	11-17-92	Blakeney et al.	430	331
C	US 2002/0042485 A1	4-11-02	Fang et al	526	209
D	5,843,624	12-1-98	Houlihan et al	430	296
E	5,716,651	7-7-98	Schaedeli et al.	430	281.1
F					
G					
H					
I					
J					
K					
L					
M					

FOREIGN PATENT DOCUMENTS

*	DOCUMENT NO.	DATE	COUNTRY	NAME	CLASS	SUBCLASS
N	JP 2000-313725	11-14-00	Japan	Ohbayashi et al		
O						
P						
Q						
R						
S						
T						

NON-PATENT DOCUMENTS

*	DOCUMENT (Including Author, Title, Source, and Pertinent Pages)	DATE
U	Chemical Abstract 2000 : 803821 - English abstract for JP 2000-313725	2000
V	Machine-Assisted English translation for JP 2000-313725 provided by Japan Patent office	2000
W		
X		

\* A copy of this reference is not being furnished with this Office action.  
(See Manual of Patent Examining Procedure, Section 707.05(a).)